



10/759,621

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PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of:

Peter J. Hopper, et al.

Appln. No.: 10/759,621

Filed: January 16, 2004

For: METHOD OF FORMING AN ETCHED  
METAL TRACE WITH REDUCED RF  
IMPEDANCE RESULTING FROM THE  
SKIN EFFECT (as amended)

Group Art Unit: 2812

Examiner: Ha T. Nguyen

AMENDMENT IN RESPONSE TO OFFICE  
ACTION MAILED AUGUST 23, 2005

INTRODUCTORY COMMENTS

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In response to the Official Action mailed August 23, 2005, please amend the  
above-identified application as indicated in the following:

**Amendments to the Claims** are reflected in the listing of claims which  
begins on page 2 of this paper; and

**Remarks** which begin on page 6 of this paper.

AMENDMENT IN RESPONSE TO OFFICE  
ACTION MAILED AUGUST 23, 2005

Atty. Docket No. 100-18311  
(P05271-D01-F1)